AMENDMENT TRANSMITTAL LETTER (Large Entity) Applicant(s): Shuichi Noda							Docket No. OKI.310	
Serial No. 10/084,192		Filing Date 02/28/2002		Deo,	Examiner Deo, Duy Vu Nguyen		Group Art Unit 1765	
Invention: METHOD FOR ETCHING AN ANTIREFLECTIVE COATING AND FOR FABRICATING A SEMICONDUCTOR DEVICE								
TO THE COMMISSIONER FOR PATENTS: Transmitted berewith is an amendment in the above-identified application. Transmitted been calculated and is transmitted as shown below.								
CLAIMS AS AMENDED								
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST #	NUMBER EXTRA R CLAIMS PRESENT		RA	TE	ADDITIONAL FEE
TOTAL CLAIMS	1	5 -	20 =	:	0	x \$	18.00	\$0.00
INDEP. CLAIMS	3	3 -	3 =	:	0	x \$	86.00	\$0.00
Multiple Dependent Claims (check if applicable)								\$0.00
TOTAL ADDITIONAL FEE FOR THIS AME						ENDME	NT	\$0.00
 No additional fee is required for amendment. □ Please charge Deposit Account No. in the amount of □ A check in the amount of to cover the filing fee is enclosed. ☑ The Director is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. □ Any additional filing fees required under 37 C.F.R. 1.16. □ Any patent application processing fees under 37 CFR 1.17. 								
Signature ADAM C VOI ENTINE								
ADAM C. VOLENTINE REG. NO. 33289								
VOLENTINE FRANCOS, PLLC 12200 SUNRISE VALLEY DRIVE, SUITE 150 RESTON VA 20191 TEL. NO. (703) 715-0870					I certify that this document and fee is being deposited on with the U.S. Postal Service as first class mail under 37 C.F.R. 1.8 and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.			
cc:	Signature of Person Mailing Correspondence							
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Serial No. 10/084,192 OKI.310 Amendment dated April 22, 2004

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent application of

Shuichi NODA : Group Art Unit 1765

Serial No. 10/084,192 : Examiner Duy Vu Nguyen Deo

Filed February 28, 2002

METHOD FOR ETCHING AN ANTIREFLECTIVE COATING AND FOR FABRICATING A SEMICONDUCTOR DEVICE

AMENDMENT

U.S. Patent and Trademark Office 2011 South Clark Place Customer Window, **Mail Stop Non-Fee Amendment** Crystal Plaza Two, Lobby, Room 1B03 Arlington, VA 22202

Sir:

In response to the final Office Action dated February 20, 2004, the following amendments and remarks are submitted:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.